DENTON

Discovery™ 18
Sputtering System

Standard Features

- Affordable
- Complete System
  - Both RF/DC sputtering power supplies are standard
- Fully Featured
  - Two magnetron sputter cathodes
  - Confocal sputtering arrangement
  - Precision mass flow control
  - Comprehensive gauges
  - Rotating substrate platform

- Clean, High Vacuum (≤10⁻⁷ torr)
  - 140 l/s turbomolecular pump
  - 11 cfm rotary vane pump
  - LN₂ trap

- Optional Accessories
  - Additional and/or larger sputter cathodes
  - Substrate load lock
  - DVOCS automation package
  - Additional power supplies
  - Capacitance manometer
  - Film thickness control

Discovery 18 Sputtering System for Research and Smaller Production Applications.
Denton Discovery™ 18
Sputtering System

VERSATILE RF AND DC MAGNETRON SPUTTERING...
IN A COMPLETE, LESS COSTLY PACKAGE FOR BOTH RESEARCH AND LIMITED PRODUCTION APPLICATIONS.

The Denton Discovery 18 has been specifically designed to fill the need for a smaller, less costly sputtering system that provides the versatility and operating benefits of larger, more costly systems. The standard system features an 18” diameter x 13.5” high deposition chamber. An optional 6.0” diameter x 10.5” long load lock allows manual transfer of substrates up to 5.0” diameter onto the substrate stage. The system’s mechanical pump evacuates the load lock. Load lock turbo pumping is available.

Chamber access to cathodes, fixtures and substrates is through a full diameter, hinged top plate. Up to three (3) magnetron sputter cathodes can be placed in the chamber top plate in a confocal arrangement. The confocal arrangement provides excellent uniformity and allows co-sputtering.
water to prevent corrosion, allow easy backing plate repair or replacement, and permit long term use of sources at high power.

All cathode assemblies are delivered with an electro-pneumatic shutter. All cathodes are RF/DC compatible. Standard RF/DC connectors and shields ensure efficient power transmission and operator safety.

**DISCOVERY 18 INTERNAL STALK-MOUNT MAGNETRON CATHODE**

- Compression fitting mount permits quick adjustment of “substrate to target” spacing
- Available in 2”, 3”, or 4” diameters
- Standard 8”-15” length
- Ideal for co-sputtering applications
- Water and electrical connections are external to vacuum
- Usable with clamped or bonded targets

**APPLICATIONS**

The Denton Discovery 18 System is used for many applications including:

- Supermodulus materials
- Superconductors
- Contact metalization
- Macro laminates
- Hybrid metalization
- Optical/magneto and optical films

**Proven Off-The-Shelf Subsystems**

A wide selection of in-stock subsystems is available to upgrade or customize any sputtering system to your specific needs.

**LOAD LOCK CHAMBER**

Denton load lock chambers are constructed from electropolished 304 stainless steel. Each load lock chamber is equipped with all required ports and feedthroughs for substrate manipulation, vacuum gauging, pumping, etc. The lock is isolated from the deposition chamber by a manual gate valve. Load lock turbo pumping to achieve high vacuum conditions is available. Since a large (6.0” diameter) load lock isolation valve is standard, substrates up to 5.0” diameter or slightly larger can be transferred through the load lock.

**RF BIAS SUBSTRATE TABLE**

Denton’s Biasable Rotating Substrate Table is available for DC to RF applications and is rated up to 5,000 volts. RF bias tables are available in 4”, 6”, 8”, and larger diameter sizes, handle weight capacities up to 100 lbs., and mount in any position for easy system integration. Robust water cooling, high purity dielectrics, and tight manufacturing tolerances ensure long, reliable life in demanding production environments.

**HIGH TEMPERATURE SUBSTRATE TABLE**

Denton’s unique Heated Rotary Substrate Tables are available as a complete system (with power supply), provide stage temperatures up to 600° or 900°C, and are capable of simultaneous heating and rotation in high vacuum (10⁻⁷ torr) applications. Table sizes of 2” and 4” are standard. Tables can be easily mounted in any position in new or existing systems. All high temperature tables feature short ramp times to operating temperature for maximum throughput, and are compatible with Denton load lock manipulators.

**RADIANT SUBSTRATE HEATER SYSTEM**

Denton’s standard SCR controlled, proportional substrate heater system provides constant temperatures and ranging capability from ambient to 300°C. Both quartz lamps and high thermal inertia calibration heaters are available.

**POWER SUPPLIES**

Denton’s 500-600 watt RF power supply with automatch network allows sputtering of nonconductive materials. An additional 500-600 watt RF power supply with automatch network is available for co-sputtering or RF bias applications.

One (1.0) KW switching DC power supply is included in the base machine for DC sputtering applications. An additional DC power supply or larger DC power supplies are optional.

**SYSTEM CONTROLS**

Denton’s user-friendly, programmable logic controller allows the user to perform standard control functions including auto venting and pumping with “soft” valve interlocks. A control interface is also offered for external automation and data acquisition.

**PRESSURE/FLOW INSTRUMENTATION**

Up to four mass flow controllers, each with a close-coupled shut-off valve can be integrated into the Discovery 18. A heated capacitance manometer with 45 psia overpressure capability may be added to improve the resolution of pressure measurements in the sputtering regime. Auto ranging cold cathode high vacuum gauging is standard. Hot filament vacuum gauging is available.
MORE STANDARD FEATURES – BETTER VALUE

* Denton’s Discovery 18 System offers these standard features so you receive a complete system and outstanding value:

- 20” Stainless Steel Base Plate and valve trap assembly
- Integral LN₂ Trap for enhanced water vapor pumping speed
- Metal Bellows, sealed electro-pneumatic high vacuum main valve, backing and roughing valves
- Microprocessor Based PLC Control of vacuum valves, auto pump/auto vent sequencing and “soft” system interlocks
- Auto Ranging Digital High Vacuum Cold Cathode Ionization Gauge and thermocouple gauges on foreline and chamber
- Precision Mass Flow Control with power supply and digital readout
- High Resolution Sputtering Pressure Gauge
- Two DVI 2.0” Diameter, Internal “Stalk-Mount” Planar Magnetron Sputter Cathodes (RI/DC) with independent shutters
- One RF Power Supply with automatich network and rack mounted control panel (500 watt)
- One 1.0 kW DC Switching Power Supply (600V-1.7 amp)
- Variable Speed (0-25 RPM) Rotating Substrate Platform

SYSTEM SPECIFICATIONS

<table>
<thead>
<tr>
<th>FEATURE</th>
<th>DISCOVERY 18</th>
</tr>
</thead>
<tbody>
<tr>
<td>Chamber</td>
<td>304L SS 18” Diameter x 13.5” Deep</td>
</tr>
<tr>
<td>Baseplate</td>
<td>304L SS 20” Diameter</td>
</tr>
<tr>
<td>High Vacuum Pump</td>
<td>140 l/s Turbomolecular Pump</td>
</tr>
<tr>
<td>Mechanical Pump</td>
<td>11 cfm</td>
</tr>
<tr>
<td>Control Cabinet</td>
<td>Single 19” Standard EIA Rack, with Single Point Power Connection</td>
</tr>
<tr>
<td>High Vacuum Gauge</td>
<td>Digital Cold Cathode Auto-Ranging</td>
</tr>
<tr>
<td>Controls</td>
<td>PLC Control of Auto Pump Sequence</td>
</tr>
<tr>
<td>Feedthroughs</td>
<td>Baseplate (15) 1.0”, (2) 2.75” Conifats (2) 1.33” Conifats</td>
</tr>
<tr>
<td>Floor Space</td>
<td>96” Wide x 48” Deep</td>
</tr>
<tr>
<td>Chamber Viewports</td>
<td>(1) 4.0” Diameter</td>
</tr>
<tr>
<td>High Vacuum Valve</td>
<td>Horizontal, 5.75” Diameter Bellows Sealed</td>
</tr>
</tbody>
</table>

Note: Specifications Subject To Change Without Notice

OTHER DENTON SYSTEMS OFFERED INCLUDE:

Vacuum Systems
Production Systems
- Sputtering, Evaporation Sources
- Bell Jars
- Box Coaters (18” to 60”)
- Ion Sources
- Optical Monitors
- Fully Automated Systems
- In-Line Sputtering Systems
Electron Microscopy
Sample Preparation Systems
- “High-Resolution” Coaters
- Sputter Coaters
- Evaporators
- Freeze Etch, Freeze Dry Systems
- Critical Point Dryers
- Ion Milling Systems, etc.
R&D/Quality Control Systems
- CV Dot Makes
- Sputtering Systems
- Electron Beam / Thermal Evaporators
Compact Disc Coating Systems
- Mastering Systems
- Q.C. Aluminizers

DENTON VACUUM INC.
1259 North Church Street
Mooresstown, NJ 08057 USA
Tel: (609) 439-9100
FAX: (609) 439-9111
© Copyright, Denton Vacuum, Inc. 1995 Printed in USA
Discovery™ is a trademark of Denton Vacuum, Inc.

THE DENTON INVITATION . . . We invite you to talk with us about any question or problem you have, any idea you have, about coating equipment and services. Simply call (609) 439-9100, write, or FAX: (609) 439-9111.

Decades of R&D in Thin Film Manufacturing

Made in America